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Docket No.: M-5091-2P US

December 21, 2001

Box Patent Application  
Commissioner For Patents  
Washington, D. C. 20231

Enclosed herewith for filing is a patent application, as follows:

Inventor(s): Papasoulotis, George D.; Tas, Robert D.; Cleemput, Patrick A. Van ; Schravendijk, Bart van

Title: Process For Depositing F-Doped Silica Glass In High Aspect Ratio Structure

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|-----------|---|
| <u>X</u>  | Return Receipt Postcard   |
| <u>X</u>  | This Transmittal Letter (in duplicate)                                    |
| <u>12</u> | Page(s) Specification (not including claims)                              |
| <u>6</u>  | Page(s) Claims  |
| <u>1</u>  | Page Abstract   |
| <u>2</u>  | Sheet(s) of Formal Drawings   |
| <u>3</u>  | Page(s) Executed Declaration For Patent Application and Power of Attorney |
| <u>1</u>  | Page NonPublication Request   |
| <u>1</u>  | Page(s) Recordation Form Cover Sheet (in duplicate)                       |
| <u>4</u>  | Page(s) Executed Assignment   |

☐ Applicant(s) assert(s) entitlement to small entity status for the attached patent applicationCLAIMS AS FILED

| For   | Number<br>Filed |     | Number<br>Extra |    | Rate |         | Basic Fee   |
|---|-----------------|-----|-----------------|----|------|---------|-------------|
| Total Claims  | 35              | -20 | =               | 15 | X    | \$18.00 | = \$ 270.00 |
| Independent Claims  | 3               | -3  | =               | 0  | X    | \$84.00 | = \$ 0.00   |
| <input type="checkbox"/> Fee of _____ for the first filing of one or more multiple dependent claims per application |                 |     |                 |    |      |         | \$          |
| <input type="checkbox"/> Fee for Request for Extension of Time  |                 |     |                 |    |      |         | \$          |

Please make the following charges to Deposit Account 19-2386:

- ☒ Total fee for filing the patent application in the amount of \$ 1,010.00
- ☒ The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account 19-2386.

EXPRESS MAIL LABEL NO:

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Respectfully submitted,

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12/21/01

JC821 U.S. PTO

10/12/01  
CL 457  
10/03/01  
OLD S N 6065CJC

**REQUEST AND CERTIFICATION  
UNDER  
35 U.S.C. 122(b)(2)(B)(i)**

Inventors

Papasoulotis, George D.; Tas, Robert D.;  
Van Cleemput, Patrick A.; Schravendijk,  
Bart van

Title

Process For Depositing F-Doped Silica Glass In  
High Aspect Ratio Structure

Atty Docket Number

M-5091-2P US

I hereby certify that the invention disclosed in the attached application **has not and will not be** the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing. I hereby request that the attached application not be published under 35 U.S.C. 122(b).

December 21, 2001

Date



Tom Chen  
Attorney for Applicants  
Reg. No.: 42,406

This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing**.

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant **must** notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. **Failure to do so will result in abandonment of this application (35 U.S.C. 122(b)(2)(B)(iii)).**